	Application No. Applicant(s)		
Notice of Allowability	10/653,514	BORKE ET AL.	
	Examiner	Art Unit	
	Robert D. Harlan	1713	
The MAILING DATE of this communication appeall claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIP of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in or other appropriate community of the community of	n this application. If not include unication will be mailed in due	ed course. <b>ŤHIS</b>
1. This communication is responsive to <u>Amendment filed on the land of the land on the land of the land on the land of the land on the land on the land of the land on the land of the lan</u>	<u>03/15/2005</u> .		
2. The allowed claim(s) is/are <u>1-5 and 7-18</u> .			•
3. The drawings filed on are accepted by the Examine	r.		
<ul> <li>4. Acknowledgment is made of a claim for foreign priority una) All b) Some* c) None of the: <ol> <li>Certified copies of the priority documents have</li> <li>Certified copies of the priority documents have</li> <li>Copies of the certified copies of the priority documents have</li> <li>International Bureau (PCT Rule 17.2(a)).</li> </ol> </li> <li>* Certified copies not received:</li> </ul> <li>Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.</li>	e been received. e been received in Application cuments have been received of this communication to file	on No  d in this national stage applicat	
5. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give	itted. Note the attached EXA es reason(s) why the oath or	AMINER'S AMENDMENT or North declaration is deficient.	OTICE OF
<ul> <li>6. ☐ CORRECTED DRAWINGS (as "replacement sheets") must (a) ☐ including changes required by the Notice of Draftspers 1) ☐ hereto or 2) ☐ to Paper No./Mail Date</li> <li>(b) ☐ including changes required by the attached Examiner's Paper No./Mail Date</li> <li>Identifying indicia such as the application number (see 37 CFR 1)</li> </ul>	son's Patent Drawing Review  S Amendment / Comment or  84(c)) should be written on the	in the Office action of ne drawings in the front (not the	back) of
each sheet. Replacement sheet(s) should be labeled as such in the 7. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT.	sit of BIOLOGICAL MATE	ERIAL must be submitted. N	lote the
Attachment(s)  1.  Notice of References Cited (PTO-892)	5 □ Notice of In	formal Patent Application (PTC	) <sub>-</sub> 152)
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. 🔲 Interview Si	ummary (PTO-413),	, 102)
3. Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date		Mail Date Amendment/Comment	
4. Examiner's Comment Regarding Requirement for Deposit	<u> </u>	Statement of Reasons for Allo	wance
of Biological Material	9.  Other		
		Robert D. Harlan Primary Examiner Art Unit: 1713	
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## DETAILED ACTION

- 1. The Amendment filed by Applicants on 03/15/05 has been entered.
- 2. Claim 6 has been canceled.

## Response to Amendment/Arguments

- 3. Applicant's amendment and arguments filed on 03/15/05 have been fully considered and they are found persuasive.
- 4. The rejection of claims 1-18 under 35 U.S.C. 103(a) as being unpatentable over the combination Meverdeen et al., U.S. Patent No. 5,312,861 (hereinafter "Meverdeen"), Wu et al., U.S. Patent No. 4,797,323 (hereinafter "Wu") and Scott, U.S. Patent No. 5,646,155 (hereinafter "Scott") is withdrawn.

## Allowable Subject Matter/Reasons for Allowance

- 5. Claims 1-5 and 7-18 are allowed.
- 6. The following is an examiner's statement of reasons for allowance: The closest prior art located or identified by the Examiner is Meverdeen, Wu and Scott. Meverdeen teaches a silane

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copolymer composition comprised of ethylene and vinyltriethoxysilane wherein the composition can undergo cure in the presence of silanol condensation catalyst. See Meverdeen, Abstract; col. 3, line 3 through col. 4, line 11. Meverdeen further teaches that the copolymer composition comprised of ethylene and vinyltriethoxysilane can be blended with a highdensity polyethylene. See Meverdeen, col. 7, lines 55-56. Wu teaches insulating compositions comprising a polyolefin and a polar organic additive. See Wu, Abstract; col. 2, line 61 through col. 3, line 8. Wu further teaches the polyolefin is polyethylene and the polar organic additive is an organic halogenated flame retardant. See Wu, Tables II & III. Scott teaches a high-density polyethylene grafted with a silane See Scott, Examples 1-3; claim 26. The present monomer. invention differs Meverdeen, Wu and Scott in that the present invention requires a high density, bimodal silane-containing polyethylene base resin.

7. As of the date of this Notice of Allowability, the Examiner has not located or identified any reference that can be used singularly or in combination with another reference including Meverdeen, Wu and Scott to render the present invention anticipated or obvious to one of ordinary skill in the art.

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8. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

## Conclusion

- 9. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Robert D. Harlan whose telephone number is (571) 272-1102. The examiner can normally be reached on Mon-Fri, 10 AM 8 PM.
- 10. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David W. Wu can be reached on (571) 273-1114. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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11. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Robert D. Harlan Primary Examiner Art Unit 1713

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